## O 76: Ultrafast Electron and spin dynamics at interfaces III

Time: Wednesday 17:30-18:30

O 76.1 Wed 17:30 MA 005

Coherent many-particle excitations in NiO ultrathin films •Konrad Gillmeister<sup>1</sup> and Wolf Widdra<sup>1,2</sup> — <sup>1</sup>Institut für Physik, Martin-Luther-Universität Halle-Wittenberg, 06120 Halle, Germany — <sup>2</sup>Max-Planck-Institut für Mikrostrukturphysik, 06120 Halle, Germany

Strong electronic correlation in NiO causes the appearance of a chargetransfer gap (CTG). Its lower and upper edges (Hubbard bands) are formed by Ni 3d electrons. In this contribution we focus on the electron dynamics after exciting electrons into the upper Hubbard band.

Using time-resolved two-photon photoemission spectroscopy (2PPE) on 1–20 monolayers (ML) NiO ultrathin films on Ag(001) we find that electrons decay within 15 fs across the CTG. However, there is a second long-living contribution to the 2PPE signal which is thicknessand temperature-dependent: periodic intensity modulations in the detected time-resolved signal near the vacuum cut-off with a lifetime of  $\sim$ 350 fs are found for NiO film thicknesses beyond 5 ML and temperatures below 470 K for 10 ML (560 K for 20 ML). These oscillations are exlained by intra-gap states which are indirectly but coherently addressed by an instantaneous decay of excited electrons and which are subsequently probed. A simultaneous excitation of magnons is also discussed.

O 76.2 Wed 17:45 MA 005

Time-resolved photoelectron spectroscopy with high-order harmonics: Surface photovoltage shift at  $SiO_2/Si(001)$  interfaces with nonlinear optical excitations —  $\bullet$ Robin Kamrla<sup>1,2</sup>, CHENG-TIEN CHIANG<sup>1,2</sup>, ANDREAS TRÜTZSCHLER<sup>1,2</sup>, MICHAEL HUTH<sup>2</sup>, FRANK OLIVER SCHUMANN<sup>2</sup>, and WOLF WIDDRA<sup>1,2</sup> — <sup>1</sup>Institute of Physics, Martin-Luther-Universität Halle-Wittenberg, Halle (Saale), Germany — <sup>2</sup>Max Planck Institute of Microstructure Physics, Halle (Saale), Germany

We investigate the fluence and doping dependence of surface photovoltage shifts (SPV) at  $SiO_2/Si(001)$  interfaces. Charge carriers are excited by 300 fs laser pulses at repetition rates of 0.2 to 0.7 MHz with photon energies of  $h\nu_{pump} = 1.2$  or  $2.4\,\mathrm{eV}$ , and subsequently probed by high-order harmonics with  $h\nu_{probe}\,{=}\,22.6\,{\rm eV}.$  On  $\rm SiO_2/p\,{-}Si(001)$ we observe a SPV of 250 meV upon excitation with  $h\nu_{pump} = 1.2 \text{ eV}$ towards higher energies, whereas on  $\mathrm{SiO}_2/\mathrm{n}$ -Si(001) the SPV reverses its sign and has a smaller magnitude of 140 meV. Upon excitation with  $h\nu_{pump} = 2.4 \text{ eV}$  a maximum SPV at SiO<sub>2</sub>/p-Si(001) of 350 meV is observed. Moreover, SPV at  $SiO_2/p$ -Si(001) shows a nonlinear fluence dependence at  $h\nu_{pump} = 1.2 \,\text{eV}$ , which significantly differs from that of  $h\nu_{pump} = 2.4 \,\text{eV}$ . In this talk the dynamics of SPV as well as its fluence dependence will be discussed.

O 76.3 Wed 18:00 MA 005 The one-step model of 2PPE in its layer-KKR formulation •JÜRGEN BRAUN and HUBERT EBERT — Dept. Chemie, LMU München, Germany

Recently a theoretical frame for the description of two-photon photoemission has been developed by the authors. The approach is based on a general formulation using the Keldysh formalism for the lesser Green function to describe the real-time evolution of the electronic degrees of freedom in the initial state after a pump pulse that drives a system out of equilibrium [1]. The fully relativistic formalism has now been generalized to angular resolution in both the initial and intermediate state by means of layer-KKR multiple scattering techniques. First examples of angular-resolved 2PPE calculations on Fe(100) will be presented. Furthermore, correlation effects will be accounted for in this spectroscopical study by means of a static self-energy  $\Sigma^{DMFT}(E)$ obtained for Fe from dynamical mean-field theory.

[1] J. Braun, R. Rausch, M. Potthoff, and H. Ebert, One-step theory of two-photon photoemission, Phys. Rev. B 94, 125128 (2016)

O 76.4 Wed 18:15 MA 005 Asymmetric electron and hole dynamics in the Rashba material  $BiTeI - \bullet$ Sophia Ketterl<sup>1</sup>, Marco Polverigiani<sup>1</sup>, Vladimir Voroshnin<sup>2</sup>, Beatrice Andres<sup>1</sup>, Alexander Shikin<sup>2</sup>, and Martin Weinelt<sup>1</sup> — <sup>1</sup>Freie Universität Berlin, Arnimallee 14, 14195 Berlin <sup>-2</sup>St. Petersburg State University, Institute of Physics, Uljanovskaya 1, 198504 St. Petersburg, Russia

Due to strong spin-orbit coupling and non-centrosymmetric crystal structure, the narrow band-gap semiconductor BiTeI hosts Rashbasplit surface and bulk bands. This makes BiTeI a promising material for the generation of spin-polarized currents. It is intrinsically n-doped and exhibits additional strong band-bending at its polar surfaces, leading to partially occupied electron- and hole-like surface states for Te and I termination, respectively.

We studied the electron and hole dynamics in the surface state and bulk conduction band on the Te-surface with time-resolved ARPES and observed a strong asymmetry for carriers close to the Fermi level. Electrons behave according to Fermi-liquid theory, while hole lifetimes decrease towards  $E_F$ . We attribute this behavior to drift currents due to the surface band bending and the influence of a plasmon decay channel as predicted by Eremeev et al. in JETP Lett. 96, 437 (2012).

Location: MA 005